

10/566116
IAP9 Rec'd PCT/PTO 24 JAN 2006

OGOSH44USA

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:)
Akihisa Inoue et al.) Examiner:
Application No.:) Group Art Unit:
Corresponding International Filing No.:)
PCT/JP2004/010361)
Filed: Herewith)
For: SPUTTERING TARGET AND)
METHOD FOR PRODUCTION)
THEREOF)

Mail Stop PCT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

SECOND PRELIMINARY AMENDMENT

Sir:

Please amend the above-identified patent application as follows.

Amendments to the Specification begin on page two of this paper.

Amendments to the Claims are reflected in the listing of claims which begins on page three of this paper.

Remarks begin on page eight of this paper.